
Contents

1. Introduction	1
2. The Electronic Structure of Atoms and Molecules	17
2.1 Early Concepts of Atomic Structure and Bonding	17
2.2 Elements of Quantum Mechanics	21
2.3 Atomic Wave Functions and Energy Eigenvalues	27
2.4 Molecular Wave Functions and Energy Eigenvalues	32
2.5 Molecular Symmetry	47
3. The Electronic Structure of Crystalline Solids	69
3.1 The Structure and Symmetry of Crystals	69
3.2 Energy Bands	90
3.3 Defects in Crystalline Solids	109
3.4 Crystal Surfaces	126
4. Semiconductor Devices and Circuits	149
4.1 <i>P-N</i> Junctions	149
4.2 Bipolar Transistors	162
4.3 MIS Capacitors and Field-Effect Transistors	167
4.4 A CMOS Processing Sequence	177
4.5 Microwave Devices	180
4.6 Confined Heterostructures	185

5. Crystal Growth

5.1 Materials Purification and Synthesis	201
5.2 Equilibrium Conditions and Kinetic Limitations of Growth	227
5.3 The Fabrication of Substrate Crystals	243

6. Epitaxy and Dielectric Deposition

6.1 Chemical Vapor Deposition at Atmospheric Pressure	285
6.2 Low-Pressure and Plasma-Enhanced Vapor Deposition	304
6.3 Organometallic Chemical Vapor Deposition	316
6.4 Molecular Beam Epitaxy and Chemical Beam Epitaxy	331

7. Pattern Definition and Etching

7.1 Photolithographic Pattern Definition	351
7.2 Ultrahigh-Resolution Patterning	358
7.3 Wet Etching	371
7.4 Dry Etching	384

8. Oxidation, Doping, and Metallization

8.1 Thermal Oxidation and Dielectric Isolation of Silicon	405
8.2 Doping by Ion Implantation and Diffusion	427
8.3 Native Oxides on III–V Surfaces	454
8.4 Schottky Barriers	470
8.5 Ohmic Contacts and Interconnects	483

9. Optical Electronics **503****Appendix A: List of Abbreviations****Appendix B: Selected Tables****Subject Index**